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Correction: Facile fabrication and photoelectrochemical properties of a one axis-oriented NiO thin film with a (111) dominant facet

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Correction for 'Facile fabrication and photoelectrochemical properties of a one axis-oriented NiO thin film with a (111) dominant facet' by Chang Woo Kim *et al.*, *J. Mater. Chem. A*, 2014, 2, 19867–19872.

There was a spelling error in the author list. The correct author list is as follows;

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The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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